

# Search Notes



Application/Control No.

10/528,111

Examiner

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Applicant(s)/Patent under Reexamination

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Art Unit

1713

*updated*

## SEARCHED

Class	Subclass	Date	Examiner
430	270.1	8-4-07	12
430	807		
430	322		
430	330		
526	248		
549	254		

## INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner
430	270.1	8-4-07	12

## SEARCH NOTES (INCLUDING SEARCH STRATEGY)

	DATE	EXMR
go over ZDS of 3-16-2005 (1 page)	4-1-07	12
check search report for PCT/JP2004/08846	4-8-07	12
go over USPTO Library search report #179391	6-27-07	12
search formula (1) & formula (2)	7-11-07	12
photoacid and (photoresist or resist)	8-4-07	12
Invetor search	8-4-07	12